The Solution for Skin Rejuvenation

NON ABLATIVE FRACTIONAL SKIN RESURFACING
ABLATIVE FRACTIONAL SKIN RESURFACING (TWAIN 2940)
SKIN REJUVENATION
WRINKLES
SCARS
MELASMA
PIGMENTED LESIONS
DYSCHROMIA
The Solution for Skin Rejuvenation

MATISSE represents the state-of-the-art in fractional laser systems for skin resurfacing and rejuvenation. Removal of wrinkles, scars, rosacea and pigmented lesions such as melasma, lentigines and dyschromia by mean of Matisse becomes extremely effective and safe.

Practitioners achieve great and reproducible aesthetical results. Matisse technology introduces a new era for laser treatments, by mean of its extremely precise multilayer fractional photothermal interaction with the skin.

FRACTIONAL SKIN RESURFACING
SKIN REJUVENATION
WRINKLES
SCARS
MELASMA
PIGMENTED LESIONS
DYSCHROMIA

Matisse is a 1540 nm ErGlass laser. This wavelength easily penetrates into the skin down to 1.5 mm and thanks to the balanced absorption by water, it stimulates the skin layers at different temperature grades. By mean of the special lens array, Matisse produces thousands of micro-columns with a high level of thermal heating and coagulation and an evenly low level thermal stimulation. Matisse treatment combines Fractional Skin Resurfacing with Non-ablative Dermal Remodelling. The combination of these two actions produces new dermal tissues in the fractional areas and achieves results similar to those obtained with traditional skin resurfacing, without downtime and related risks for the patients.

No anesthesia or gel are requested thanks to the use of an integrated skin cooler. This ensures fast treatments and painless sensations to the patients.

Matisse is designed to achieve greater safety and reduced side effects. Matisse technology provides proven and superior clinical results compared to other fractional or non-ablative skin rejuvenation systems.

FEATURES
• ER:Glass laser @1540 nm
• Integrated Skin Cooler
• Can be combined with other lasers or IPL

TWAIN universal connector
Matisse has a special connector for TWAIN IPL and TWAIN 2940 optional handpieces upgrading.

TWAIN connector
Matisse is available also in combination with other laser modules or light sources. *Matisse VT* incorporates a Nd:Yag 1064 and 1320 nm laser. *Matisse HR* incorporates an Alexandrite 755 nm laser. *Matisse QS* is equipped with a Q-Switched Nd:Yag 1064 and 532 nm laser. *Matisse PL* is equipped with a TWAIN IPL source. The availability of different Matisse versions is of great advantage in terms of space and cost optimization.

**OPTIONS**

**Twain 1320**
Optional for any Nd:Yag of this series is the 1320 nm wavelength. Thanks to its higher absorption by water and great penetration into the dermis, it is very effective for collagen remodeling through the fibroblasts stimulation. It consequently enhances the applications of the system on:
- Fine wrinkles
- Enlarged pores
- Acne scars
- Keloids
- Smoothness and skin lifting
- Skin rejuvenation

**Twain 2940**
Optional for each series is a Erbium Yag laser all built into a handpiece. Through this module both fractional and traditional ablative skin resurfacing procedures are possible. This TWAIN represents the ideal solution for fast skin texture and wrinkle improvement.

Applications:
- Ablative Fractional Resurfacing
- Skin peels
- Removal of benign skin lesions

**Twain IPL**
Matisse can be equipped, at any time, with an optional IPL, enhancing flexibility and versatility.

It allows the following treatments:
- Hair removal
- Pigmented lesions
- Skin Rejuvenation
- Vascular treatments
- Active acne

**Twain RF**
Optional for this series is a highly controllable RF energy module, for non invasive procedures such as firming of deep tissues, skin tightening and contouring.

RF tightens and shrinks dermal and sub-dermal tissues reducing skin laxity and renewing contours.

For more information please browse the Quanta System’s website: www.quantasystem.com
Quanta System's products are manufactured according to the International standards and have been cleared by the most important International notified bodies. The Company is UNI EN ISO 9001:2008 and UNI EN ISO 13485:2003/4 certified.

Quanta System S.p.A. was funded in 1985 and belongs to the EI. En Group (a public company listed on the Star segment of the Italian Stock Exchange) since January 2004. The company, divided into three business units (scientific, industrial and medical) is specialized in laser and opto-electronic devices.

**Matisse QS model: the only 1064 + 532 nm Q-Switched + Fractional Er:GLASS 1540nm laser all into one unit.**

Please browse [www.quantasystem.com](http://www.quantasystem.com) for more information.

Specifications are subject to change without notice.

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**Twain 2940**

- **Source**: Er:YAG
- **Wavelength (nm)**: 2940
- **Pulse width (ms)**: 0.3 to 1
- **Spot size (mm)**: 4 to 10
- **Fluence (J/cm²)**: 8
- **Repetition rate (Hz)**: up to 6

**Twain IPL**

- **Source**: IPL handpieces
- **Wavelength (nm)**: 650-1200, 625-1200
- **Pulse width (ms)**: up to 300
- **Spot size (mm)**: 13x48 mm² - 13x25 mm²
- **Fluence (J/cm²)**: up to 20
- **Repetition rate (Hz)**: 0,5

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<table>
<thead>
<tr>
<th>MODEL</th>
<th>Matisse</th>
<th>Matisse HR</th>
<th>Matisse VT</th>
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<tbody>
<tr>
<td><strong>Source</strong></td>
<td>Er:Glass</td>
<td>Er:Glass</td>
<td>Er:Glass</td>
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<tr>
<td><strong>Wavelength (nm)</strong></td>
<td>1540</td>
<td>1540</td>
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</tr>
<tr>
<td><strong>Pulse width (ms)</strong></td>
<td>up to 14</td>
<td>up to 14</td>
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<tr>
<td><strong>Spot size (mm)</strong></td>
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<td>up to 16</td>
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<tr>
<td><strong>Fluence (J/cm²)</strong></td>
<td>up to 250 per microspot</td>
<td>up to 250 per microspot</td>
<td>up to 250 per microspot</td>
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<tr>
<td><strong>Skin cooling</strong></td>
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<td>yes</td>
<td>yes</td>
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<tr>
<td><strong>Repetition rate (Hz)</strong></td>
<td>up to 1</td>
<td>up to 1</td>
<td>up to 2</td>
</tr>
<tr>
<td><strong>Electrical requirements</strong></td>
<td>220 - 230 V AC; 16 A; 50-60 Hz</td>
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<tr>
<td><strong>Dimensions and weight</strong></td>
<td>480 (L) x 900 (W) x 930 (H) mm³; 85 Kg</td>
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(i) Optional: 1320 nm available on request